

**1. Scope :**

This specification applies to N/P silicon zener diode chips,  
Device NO. SD-40812GVA

**2. Structure :**

- 2-1. Planar type : N/P Diode
- 2-2. Electrodes :  
Top side : Gold pad.  
Back side : SnAu alloy.

**3. Size :**

- 3-1. \*1 Chip size : 8.5 mils x 8.5 mils (0.215 mm x 0.215 mm ).
- 3-2. Chip thickness :  $4.0 \pm 1.0$  mils ( $0.100 \pm 0.025$  mm ).
- 3-3. Active area : 5.3 mils x 5.3 mils (0.135 mm x 0.135 mm).
- 3-4. \*2 Bonding pad : 5.9 mils x 5.9 mils (0.150 mm x 0.150 mm) .
- 3-5. Pattern drawing : Refer to the attached drawing.

\*1 Including scribing line. The chip size is about  $(0.190 \pm 0.015)^2 \text{mm}^2$  after dicing.

\*2 The bonding pad dimension is  $(0.150 \pm 0.015)^2 \text{mm}^2$ .

**4. Electrical characteristics (Ta = 25 °C)**

| Parameter                  | Symbol | Condition                                  | Min. | Typ. | Max. | Unit |
|----------------------------|--------|--|------|------|------|------|
| *3 Reverse Leakage Current | $I_R$  | $V_R=8V$<br>$E_e=0\text{mW/cm}^2$          |      |      | 100  | nA   |
| *3 Zener Voltage           | $V_Z$  | $I_Z=5\text{mA}$<br>$E_e=0\text{mW/cm}^2$  | 9    |      | 15   | V    |
| *3 Forward Voltage         | $V_f$  | $I_f=20\text{mA}$<br>$E_e=0\text{mW/cm}^2$ |      |      | 1.2  | V    |

\*3 Based on 100% probing.

